



Title: Plasma Etch Releases New R&D Scale Plasma Cleaner

For Immediate Release:

Carson City, NV – Plasma Etch Inc, a leader in plasma innovation, recently announced the PE-Avenger, a new ultra low-cost entry level plasma cleaning system designed for R&D work. With a 3” by 4” working area, this system is also a great value for folks working with small substrate sizes.

The system is a low frequency plasma cleaner designed for surface activation and organics removal. Surface activation allows nearly any material, even hydrophobic materials like Teflon, to be bonded to or printed on.

The PE-Avenger is fully automated and easy to use. With a price point of only \$4,900. The company believes this new system is the best value on the market for any plasma cleaner!

This newest addition to Plasma Etch's line of systems is available to order on their website: <https://www.plasmaetch.com/pe-avenger.php>

About Plasma Etch: Plasma Etch has been a leading manufacturer and industry innovator since 1980. The company holds several patents for the invention, development, and manufacturing of groundbreaking innovations, paving the way for plasma technology and the enhancement of quality manufacturing worldwide. Plasma Etch specializes in plasma cleaning solutions of all sizes. Their products are industry proven and set the standard for reliability, speed, and uniformity in plasma processing.

Contact information:
Plasma Etch, Inc.
3522 Arrowhead Drive
Carson City, NV 89706
(775) 883-1366
www.plasmaetch.com

###